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#G01

The use of Kendrick mass defect plots, a new feature in GC Image[™] software for GC x GC/high resolution mass spectrometric data analysis: an application on the identification of halogenated contaminants in electronic waste

jsb

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Introduction

The combination of GC x GC with high resolution mass spectrometry (HRMS) is a powerful tool for the analysis of complex mixtures. Hundreds/thousands of components can be separated and detected. However, interpreting the data sets generated by a GC x GC/high resolution time-of-flight mass spectrometry system can be challenging due to the unprecedented amount of information the data offers.

In 1963, Edward Kendrick realized that by converting the International Union of Pure and Applied Chemistry (IUPAC) mass scale (C = 12.000 Da) to one in which $CH_2 = 14.000$ Da (equation 1), organic ions belonging to a homologous series have identical Kendrick mass defect (equation 2). An example of Kendrick mass and Kendrick mass defect for methyl, ethyl, and propyl naphthalene is listed in Table 1. This approach greatly simplifies the high resolution mass spectrometric data analysis ^[1].

Kendrick mass = IUPAC mass x (14/14.01565) (1)

Kendrick mass defect = nominal Kendrick mass – exact Kendrick mass (2)

| Table 1. Kendrick Mass Defect for Naphthalenes | | | | | | |
|---|---------------|----------------------|--|--|--|--|
| Compound | Kendrick Mass | Kendrick Mass Defect | | | | |
| Methyl naphthalene (C ₁₁ H ₁₀) | 141.9195 | 0.0805 | | | | |
| Ethyl naphthalene (C ₁₂ H ₁₂) | 155.9195 | 0.0805 | | | | |
| Propyl naphthalene (C ₁₃ H ₁₄) | 169.9195 | 0.0805 | | | | |

In this study, nontraditional Kendrick mass defect by the substitution of a hydrogen with a chlorine atom was used to facilitate the identification of halogenated components in an electronic waste sample ^[2]. The capability of constructing Kendrick mass defect plots has been implemented into GC Image[™] software version 2.5.



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Method

Sample analysis

A dust sample collected from an electronic recycling facility was analyzed by using GC x GC (Zoex ZX2 thermal modulator) in combination with a new high-resolution time-of-flight (TOF) mass spectrometer (JEOL *AccuTOF GCv 4G*). The instrument parameters are listed in Table 2.

| Table 2. Instrument Parameters | | | | | | |
|--------------------------------|--|--|--|--|--|--|
| Conditions | GC x GC/EI | | | | | |
| Sample | Dust collected from an electronic recycling facility | | | | | |
| GC x GC system | Zoex ZX2 thermal modulator | | | | | |
| 1st column | Rxi-5SilMS, 30 m x 0.25 mm, 0.25 μm | | | | | |
| 2nd column | Rxi-17SilMS, 2 m x 0.15 mm, 0.15 μm | | | | | |
| Modulation loop | Deactivated fused silica, 1.5 m x 0.15 mm | | | | | |
| Modulation period | 8 s | | | | | |
| Modulation duration | 400 ms | | | | | |
| Inlet mode | Splitless, constant flow | | | | | |
| Oven temp. | 50 °C (1 min) -> 5 °C/min -> 320 °C (5 min) | | | | | |
| GC-TOFMS system | AccuTOF GCv 4G (JEOL) | | | | | |
| Ionization mode | EI+, 70 eV | | | | | |
| Ionization current | ent 300 μA | | | | | |
| lon source temp. | 250 °C | | | | | |
| MS transfer line temp. | 280 °C | | | | | |
| m/z range | m/z 45-800 | | | | | |
| Acquisition time | 20 ms (50 Hz) | | | | | |
| Software | GC Image [™] Version [™] 2.5 | | | | | |

Mass calibration

A single point external mass calibration with one column bleed ion $C_5H_{15}O_3Si_3^+$, m/z 207.0329 was performed after data acquisition.

Kendrick mass defect plot

An average mass spectrum for the entire retention time region was created by summing the mass spectra for all data points in a GC x GC/HRMS data set. Nontraditional Kendrick mass defect (H/Cl mass defect) was calculated. Kendrick mass defect plot was constructed with the nominal mass vs. the corresponding mass defect for each peak in the average mass spectrum.





Results and Discussion

Figure 1 shows the GC x GC total ion chromatogram for an electronic waste sample. An average mass spectrum for the entire retention time region was generated and showed in Figure 2. The exact mass for each ion was converted to H/Cl mass (equation 3) and an H/Cl mass defect plot for the average mass



spectrum was constructed and showed in Figure 3 automatically with GC Image[™] software version 2.5.



Fig.2 Average mass spectrum for the entire retention time region

H/Cl mass = IUPAC mass x (34/33.96102) (3)

Figure 3 shows that ions in each class of halogenated compounds differing by H/Cl substitution align with the horizontal axis since they have the same H/Cl mass defect. Those compounds can be easily, immediately recognized visually in the H/Cl mass defect plot. This greatly simplified halogenated compounds identification in a complex GC x GC chromatogram. By drawing a polygon around each class of halogenated compounds, mass chromatograms can be generated automatically. Figure 4 shows the high resolution GC x GC mass chromatograms for the most abundant

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Fig. 3 H/Cl mass defect plot for the average mass spectrum

isotope ions for each class of halogenated compounds. The NIST library search and exact mass measurement were used to confirm the identification. The exact mass measurement results are listed in Table 4.



Fig. 4 GC x GC mass chromatograms for the most abundant isotope ions ± 50 ppm (a) TCPP, (b) polychlorinated terphenyl, (c) tetrabromobisphenol A, (d) PCBs, (e) PBDEs, and (f) hexabromobenzene



| Table 4. Exact mass measurement results | | | | | | | |
|---|--------|----------------------------|-------------|------------|------------|--|--|
| Compound | | Elemental | Theoretical | Measured | Difference | | |
| | | Composition | Mass | Mass | (mmu) | | |
| ТСРР | | $C_8H_{13}CI_5O_4P^{\ast}$ | 380.895910 | 380.896356 | -0.446 | | |
| Terphenyls | Cl 8 | $C_{18}H_6CI_8^+$ | 505.791323 | 505.791346 | -0.023 | | |
| | Cl9 | $C_{18}H_5CI_9^+$ | 539.752351 | 539.752675 | -0.324 | | |
| | Cl10 | $C_{18}H_4CI_{10}^+$ | 573.713378 | 573.714726 | -1.348 | | |
| | Cl11 | $C_{18}H_3CI_{11}^+$ | 607.674406 | 607.675086 | -0.68 | | |
| Tetrabromobis A | ohenol | $C_{14}H_9Br_4O_2^+$ | 528.728964 | 528.728857 | 0.107 | | |
| PCBs | Cl4 | $C_{12}H_6Cl_4^+$ | 291.918862 | 291.918259 | 0.603 | | |
| | CI5 | $C_{12}H_5CI_5^+$ | 325.879890 | 325.879644 | 0.246 | | |
| | Cl6 | $C_{12}H_4CI_6^+$ | 359.840918 | 359.840915 | 0.003 | | |
| | CI7 | $C_{12}H_3Cl_7^+$ | 393.801945 | 393.802354 | -0.409 | | |
| | CI8 | $C_{12}H_2CI_8^+$ | 429.760023 | 429.760063 | -0.04 | | |
| PBDEs | Br2 | $C_{12}H_8Br_2O^+$ | 327.891595 | 327.891217 | 0.378 | | |
| | Br3 | $C_{12}H_7Br_3O^+$ | 405.802108 | 405.801461 | 0.647 | | |
| | Br4 | $C_{12}H_6Br_4O^+$ | 485.710574 | 485.709147 | 1.427 | | |
| | Br5 | $C_{12}H_5Br_5O^+$ | 563.621087 | 563.620149 | 0.938 | | |
| | Br6 | $C_{12}H_4Br_6O^+$ | 643.529553 | 643.529852 | -0.299 | | |
| | Br7 | $C_{12}H_3Br_7O^+$ | 721.440066 | 721.439888 | 0.178 | | |
| Hexabromobenzene | | $C_6Br_6^+$ | 551.503338 | 551.502866 | 0.472 | | |

Conclusion

The combination of GC x GC with high resolution time-of-flight mass spectrometry is a powerful tool for analysis of complex mixtures. The halogenated compounds can be easily, immediately, and visually distinguished in a very complicated GC x GC chromatogram by using H/Cl mass defect plots – a new feature in GC Image software[™] version 2.5. The identification is further confirmed by NIST library search and the exact mass measurement results.

References

 Edward Kendrick, A mass scale based on CH2 = 14.000 for high resolution mass spectrometry of organic compounds, Anal. Chem (1963) 35:2146 – 2154

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